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Overcoming passivation through improved mass transport in dense ionic fluids

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Supplementary Information

Table S1: Source, purity, and diameter of the metal wires used to form the working electrodes and pseudo reference electrodes.

Metal Wire	Purity	Source	Diameter (mm)
Copper	99.00%	RS	1.25
Nickel	98.00%	VWR	1.00
Cobalt	99.995%	Alfa-Aesar	1.00
Silver	99.90%	Alfa-Aesar	0.50
Aluminium	>98.00%	Unicorn Metals	3.00
Titanium	Grade 5 >98.00%	Unicorn Metals	3.00

Table S2: Literature values for viscosity and conductivity of the three choline chloride systems investigated.

Solvent	[Cl ⁻] / mol kg ⁻¹ of total solvent	Density / g cm ⁻³	Viscosity / mPa s	Conductivity / mS cm ⁻¹	Literature	
ChCl:2EG	3.79	1.12	37	7.61	lit *	
1:3 Brine	5.16	1.097(4)	14.08(6)	43.3(3)	lit **	
1:6.85 Brine	3.79	1.057(5)	4.19(9)	83.1(6)	this work	
* Data taken from T. Isono, J. Chem. Eng. Data, 1984, 29 , 45-52						
** Data taken from G. Zante et al, Angew. Chem. Int. Ed. Eng., 2023, 62, e202311140						

Table S3: Table showing the parameters used for calculation of the copper(I) concentration at the solvent-electrode interface at the point of passivation for three different ChCl systems. E_{ox} is the onset potential of copper oxidation, E_{pass} is the potential at which the peak current is observed under silent conditions and $[Cu^+]_{x=0}$ is the concentration of Cu(I) at the electrode interface prior to the onset of electrode passivation.

Voltage scan rate / V s ⁻¹	D(Cu ⁺) / m ² s ⁻¹ *	Peak anodic current density / A m ⁻ ²	E _{ox} _E _{pass} / ∨	$[Cu^+]_{x=0}$ / mol dm ⁻³	$[Cu^+]_{x=0}$:[Cl ⁻]bulk		
0.01	8.57 x 10 ⁻¹²	393	0.44	4.61	1.09		
0.05	8.57 x 10 ⁻¹²	823	0.66	5.29	1.25		
0.1	8.57 x 10 ⁻¹²	1172	0.76	5.72	1.35		
1:3 ChCl:water, [Cl ⁻] = 5.70 mol dm ⁻³							
Scan rate / V s ⁻¹	D(Cu⁺) / m² s⁻¹ †	Peak anodic current density / A m ⁻ ²	E _{ox} _E _{pass} / V	$[Cu^{+}]_{x=0}$ / mol dm ⁻³	$[Cu^+]_{x=0}$:[Cl ⁻] _{bulk}		
0.01	1.55 x 10 ⁻¹¹	695	0.29	4.94	0.87		
0.05	1.55 x 10 ⁻¹¹	1308	0.42	4.99	0.88		
0.1	1.55 x 10 ⁻¹¹	1667	0.49	4.86	0.86		
1:6.85 ChCl:water, [Cl ⁻] = 4.02 mol dm ⁻³							
Scan rate / V s ⁻¹	D(Cu ⁺) / m ² s ⁻¹ ‡	Peak anodic current density / A m ⁻ ²	E _{ox-} E _{pass} / V	$[Cu^{+}]_{x=0}$ / mol dm ⁻³	[<i>Cu</i> ⁺] _{x=0} :[Cl ⁻] _{bulk}		
0.01	1.09 x 10 ⁻¹⁰	940	0.22	1.69	0.42		
0.05	1.09 x 10 ⁻¹⁰	1847	0.32	1.79	0.45		
0.1	1.09 x 10 ⁻¹⁰	2412	0.39	1.83	0.46		
* Diffusion coefficient from A. Y. M. Al-Murshedi, et al., <i>Trans. IMF</i> , 2019, 97 , 321-329 † Diffusion coefficient from G. Zante, et al., <i>Angew. Chem. Int. Ed. Eng.</i> , 2023, 62 , e202311140							

ChCl:2EG, [Cl⁻] = 4.25 mol dm⁻³

Diffusion coefficient from G. Zante, et al., Angew. Chem. Int. Ed. Eng., 2023, 62, e202311140
Diffusion coefficient estimated via interpolation of data reported in G. Zante, et al., Angew. Chem. Int. Ed. Eng., 2023, 62, e202311140.



Figure S1: Effect of scan rate on the LSVs of a copper disc working electrode under silent and ultrasonic conditions (53 and 132 W cm⁻²). The quasi-reference electrode was a copper wire, and the counter electrode was an iridium oxide-coated titanium mesh. Measurements were carried out at room temperature.



electrodes in ChCl:2EG and two different ChCl brines, under a, c, e) silent, and b, d, f) 132 W cm⁻². The reference electrode was the same metal as the working electrode, and the scan rate was 10 mV s⁻¹. First scans presented only.



Figure S3: Effect of scan rate on the LSVs of a silver disc working electrode under silent and ultrasonic conditions (53 and 132 W cm⁻²). The quasi-reference electrode was a silver wire, and the counter electrode was an iridium oxide-coated titanium mesh. Measurements were carried out at room temperature.



Figure S4: Effect of scan rate on the LSVs of a nickel disc working electrode under silent and ultrasonic conditions (53 and 132 W cm⁻²). The quasi-reference electrode was a nickel wire, and the counter electrode was an iridium oxide-coated titanium mesh. Measurements were carried out at room temperature.



Figure S5: Effect of scan rate on the LSVs of a cobalt disc working electrode under silent and ultrasonic conditions (53 and 132 W cm⁻²). The quasi-reference electrode was a cobalt wire, and the counter electrode was an iridium oxide-coated titanium mesh. Measurements were carried out at room temperature.



Figure S6: Effect of scan rate on the LSVs of an aluminium disc working electrode under silent and ultrasonic conditions (53 and 132 W cm⁻²). The quasi-reference electrode was an aluminium wire, and the counter electrode was an iridium oxide-coated titanium mesh. Measurements were carried out at room temperature.



Figure S7: Effect of scan rate on the LSVs of a titanium disc working electrode under silent and ultrasonic conditions (53 and 132 W cm⁻²). The quasi-reference electrode was a titanium wire, and the counter electrode was an iridium oxide-coated titanium mesh. Measurements were carried out at room temperature.



conditions, and b, d) 132 W cm⁻² ultrasound. The scan rate was 10 mV s⁻¹, with a quasi-reference electrode made from the same metal as the metal under investigation.